



REPLY UNDER 37 C.F.R. § 1.116 EXPEDITED PROCEDURE EXAMINING GROUP 1752

> PATENT 2224-0163P

BOX AF

IN THE U.S. PATENT AND TRADEMARK OFFICE

Applicant:

Tatsuya NAKANO

Conf.:

5816

Appl. No.:

09/463,059

Group:

1752

Filed:

January 19, 2000

Examiner: THORNTON

For:

ACID-SENSITIVE COMPOUND AND RESIN

COMPOSITION FOR PHOTORESIST

LARGE ENTITY TRANSMITTAL FORM FOR REPLY AFTER FINAL UNDER 37 C.F.R. § 1.116

BOX AF

Assistant Commissioner for Patents Washington, DC 20231

February 19, 2003 (Day After Holiday)

Sir:

Transmitted herewith is an amendment in the above-identified application.

The enclosed document is being transmitted via the Certificate of Mailing provisions of 37 C.F.R. § 1.8.

The enclosed document is being transmitted via facsimile.

The fee has been calculated as shown below:

	CLAIMS REMAINING AFTER AMENDMENT		HIGHEST NUMBER PREVIOUSLY PAID FOR		PRESENT EXTRA	RATE	ADDITIONAL FEE
TOTAL	12	-	20	=	0	\$ 18	\$0.00
INDEPENDENT	2	-	3	=	0	\$ 84	\$0.00
FIRST PRESENTATION OF A MULTIPLE DEPENDENT CLAIM						\$280	\$0.00
BNGUYEN1 00000093 09463059							\$0.00

02/20/2003 BNBUYEH1 00000093 09463

410.00 OP

01 FC:1252

Appl. No. 09/463,059

(Rev. 09/30/02)

\boxtimes		extension of time pursuant to 37 . \$410.00 for the extension of
	No fee is required.	
\boxtimes	Check(s) in the amount of \$4	10.00 is(are) enclosed.
	Please charge Deposit Accou \$0.00. This form is submitte	nt No. 02-2448 in the amount of d in triplicate.
overp requi	current, and future replies, rpayment to Deposit Account No	er is hereby authorized in this, to charge payment or credit any . 02-2448 for any additional fees 1.17; particularly, extension of
	Resp	ectfully submitted,
	BIRC	H, STEWART, KOLASCH & BIRCH, LLP
•	P.O. Fall	A 28,78, aymond C. Stewart, #21,066 Box 747 s Church, VA 22040-0747
2224-	4-0163P (703) 205-8000
Attac	achment (a)	



BOX AF EXPEDITED PROCEDURE GROUP 1752

PATENT 2224-0163P

IN THE U.S. PATENT AND TRADEMARK OFFICE

Applicant:

Tatsuya NAKANO

Conf.:

5816

Appl. No.:

09/463,059

Group:

1752

Filed:

January 19, 2000

Examiner: THORNTON

For:

ACID-SENSITIVE COMPOUND AND RESIN

COMPOSITION FOR PHOTORESIST

AMENDMENT UNDER 37 CFR 1.116

BOX AF Assistant Commissioner for Patents

Washington, DC 20231

February 19, 2003 (Day after Holiday)

Sir:

Responsive to the Office Action of September 16, 2002, the period for responding having been extended two (2) months until Sunday, February 16, 2003, please enter the following amendments and remarks into the file of the above-identified application.

IN THE CLAIMS:

Cancel claims 5-7, without disclaimer or prejudice.